

Micronic Laser Systems nomination committee for AGM 2009

In accordance with previous decision at Micronic's annual general meeting a nomination committee consisting of, the at the end of September, the four largest shareholders and the chairman of the board should be appointed. The nomination committee shall for the AGM 2009 propose members and chairman of the board and remuneration to the board members and auditors.

Nomination committee:

Ulf Strömsten, Catella

Anders Ljungqvist, AMF

Annika Andersson, Fjärde AP-fonden

Ramsay Brufer, Alecta

Christer Elmhagen, Chairman of the board

Annika Andersson has been appointed as chairman of the nomination committee.

Next AGM will take place on April 1, 2009

Shareholders, who would like to give proposals should do that in writing on January 31, 2009 at the latest to the address below:

Micronic Laser Systems
Valberedningen
Box 3141
S-183 03 Täby
Sweden

For further information:

Annika Andersson, the chairman via Ankie Jörgne, e-mailaddress: ankie.jorgne@micronic.se

About Micronic Laser Systems AB

Micronic Laser Systems AB is a Swedish high-tech company engaged in the development, manufacture and marketing of a series of extremely accurate laser pattern generators for the production of photomasks. The technology involved is known as microlithography. Micronic's product offering also includes metrology systems for display photomasks. Micronic's systems are used by the world's leading electronics companies in the manufacture of television and computer displays, semiconductor circuits and semiconductor packaging components. Micronic is located in Täby, north of Stockholm and at present has subsidiaries in the United States, Japan, South Korea and Taiwan. Micronic maintains a web site at: <http://www.micronic.se>